SUPPORTING INFORMATION

Tetraphenylethene (TPE) modified polyhedral oligomeric silsesquioxanes (POSS): unadulterated monomer emission, aggregation-induced emission and nanostructural self-assembly modulated by the flexible spacer between POSS and TPE

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Fig. S26 Illustration of self-assembly of TPE-modified POSS molecules in THF and THF/water. (19)

Experimental

General.

All synthetic manipulations were carried out under an atmosphere of dry argon gas using standard vacuum-line Schlenk techniques. All solvents were degassed and purified before use according to standard literature methods. Diethyl ether, hexanes, tetrahydrofuran, and toluene were purchased from Aldrich Chemical Co. Inc. and distilled from sodium/benzophenone ketyl before use.

Instrumentation.

¹H and ¹³C nuclear magnetic resonance (NMR) spectra were recorded on a Bruker DRX 400-MHz NMR spectrometer in CDCl₃ at room temperature using tetramethylsilane (TMS) as an internal standard. Operating frequencies of the NMR spectrometer were 400.13 MHz (¹H) and 100.61 MHz (¹³C). MALDI-TOF was recorded using a Bruker Autoflex III TOF/ TOF. Elemental analysis was conducted on a Perkin-Elmer 240C elemental analyzer for C, H, and N determination. UV-vis and fluorescence spectra were obtained using a Shimadzu UV3101PC UV-vis-NIR spectrophotometer and a Perkin-Elmer LS 50B luminescence spectrometer with a Xenon lamp as light source, respectively. Thermal analysis was performed on a Perkin-Elmer thermogravimetric analyzer (TGA 7) in nitrogen or in air at a heating rate of 20 °C/min and on a TA Instruments Differential Scanning Calorimetry (DSC) 2920 at a heating rate and a cooling rate of 5 °C/min in nitrogen. Dynamic light scattering experiments were performed on a Brookhaven 90 plus spectrometer with a temperature controller. An argon ion laser operating at 633 nm was used as light source.

General procedure for thiol-ene click reaction.

A 5 mL schlenk flask was charged with compound **1** (445.8 mg, 0.5 mmol), Precursor-1 (307.4 mg, 0.5 mmol) and 1,4-Diazabicyclo[2.2.2]octane (DABCO, 5.6 mg, 0.005 mmol) was dried under reduced pressure at 60 °C for 2 hours. It was then cooled to room temperature and anhydrous dimethyl sulfoxide/tetrahydrofuran (DMSO/THF, 2 mL, 1:1v/v), was introduced under argon atmosphere and purge for 15 mins. The reaction mixture was then heated to 60 °C overnight with stirring, then mixture was cooled to room temperature and extracted with CH_2Cl_2 and washed with deionised water. The organic phase was isolated and dried over $MgSO_4$, followed by filtration and solvent was then removed under vacuum. The white crude product was purified via column chromatography on SiO₂ using CH_2Cl_2 /hexane, 1:3 (v/v) as eluent to yield POSS-AN₈ as pale yellow gel-like solid.

POSS-AN₈. Yield: 61.2%; ¹H NMR (CDCl₃): δ 7.07-7.12 (m, 9H), 6.99-7.04 (8H, m), 6.84 (d, 2H, *J* = 8.8 Hz), 2.76-2.87 (m, 4H), 2.57 (t, 2H, *J* = 7.3 Hz), 1.79-1.91 (m, 7H), 1.70 (m, 2H), 0.95 (m, 42H), 0.69-0.74 (m, 2H), 0.60 (m, 14H). ¹³C NMR (CDCl₃): δ 170.7, 132.7, 131.8, 131.7, 128. 2, 128.1, 128.0, 127.0, 126.9, 121.1, 35.5, 35.4, 30.1, 27.1, 26.1, 24.3, 24.2, 23.4, 22.8, 22.9, 12.0. ²⁹Si NMR (CDCl₃): δ -59.0. IR (thin film): v = 3054, 3025, 2954, 2929, 2927,

2870, 1764, 1599, 1503, 1466, 1445, 1402, 1384, 1367, 1333, 1231, 1106, 954, 922, 867, 838, 802, 762, 746, 700 cm⁻¹. MALDI-TOF: [M] calcd for $C_{60}H_{92}O_{14}SSi_8$, m/z 1292.43; found, m/z 1292.31. Anal. Calcd for $C_{60}H_{92}O_{14}SSi_8$: C, 55.69; H, 7.17; S, 2.48; Si, 17.36. Found: C, 55.61; H, 7.29; S, 2.44; Si, 17.31.

POSS-AN₁₅. Yield: 58.4%; ¹H NMR (CDCl₃): δ 6.99-7.14 (m, 15), 6.91 (d, 2H, *J* = 8.8 Hz), 6.62 (d, 2H, *J* = 8.9 Hz), 4.10 (t, 2H, *J* = 4.1 Hz), 3.87 (t, 2H, *J* = 6.5 Hz), 2.76 (t, 2H, *J* = 7.5 Hz), 2.59 (t, 2H, *J* = 7.6 Hz), 2.54 (t, 2H, *J* = 7.3 Hz), 1.80-1.91 (m, 7H), 1.61-1.78 (m, 6H), 1.36-1.51 (m, 4H), 0.96 (m, 42H), 0.68-0.74 (m, 2H), 0.60 (m, 14H). ¹³C NMR (CDCl₃): δ 172.4, 158.0, 144.5, 144.4, 141.1, 140.4, 136.4, 131.8, 131.8, 131.7, 128.1, 128.0, 126.7, 126.6, 114.0, 68.0, 65.1, 35.4, 35.3, 32.3, 31.8, 30.6, 30.1, 29.6, 29.0, 27.2, 26.2, 26.1, 26.0, 24.3, 24.2, 23.4, 22.9, 22.8, 12.0. ²⁹Si NMR (CDCl₃): δ -59.0. IR (thin film): *v* = 3054, 3025, 2954, 2930, 2869, 1739, 1606, 1508, 1493, 1466, 1444, 1402, 1384, 1367, 1333, 1231, 1107, 839, 762, 745, 699 cm⁻¹. MALDI-TOF: [M] calcd for C₆₆H₁₀₄O₁₄SSi₈, m/z 1376.53; found, m/z 1376.69. Anal. Calcd for C₆₆H₁₀₄O₁₄SSi₈: C, 57.51; H, 7.61; S, 2.33; Si, 16.30. Found: C, 57.39; H, 7.70; S, 2.31; Si, 16.22.

POSS-AN₂₁. Yield = (59.1%). ¹H NMR (CDCl₃): δ 6.99-7.14 (m, 15), 6.91 (d, 2H, *J* = 8.9 Hz), 6.62 (d, 2H, *J* = 8.8 Hz), 4.08 (m, 2H), 3.86 (m, 2H), 2.76 (t, 2H, *J* = 7.5 Hz), 2.59 (t, 2H, *J* = 7.5 Hz), 2.54 (t, 2H, *J* = 7.4 Hz), 1.79-1.91 (m, 7H), 1.58-1.76 (m, 4H), 1.24-1.45 (m, 18H), 0.95 (m, 42H), 0.68-0.74 (m, 2H), 0.60 (m, 14H). ¹³C NMR (CDCl₃): δ 158.1, 144.5, 144.4, 132.9, 131.8, 131.7, 128.1, 128.0, 126.7, 126.6, 114.0, 68.2, 65.3, 35.4, 31.8, 30.1, 30.0, 29.9, 29.8, 29.7, 29.6, 29.0, 27.2, 26.5, 26.3, 26.1, 24.3, 24.2, 23.4, 22.9, 22.9, 12.0. ²⁹Si NMR (CDCl₃): δ - 59.0. IR (thin film): *v* = 3054, 3025, 2954, 2926, 1739, 1607, 1508, 1466, 1367, 1333, 1231, 1109, 839, 745, 699 cm⁻¹. MALDI-TOF: [M] calcd for C₇₂H₁₁₆O₁₄SSi₈, m/z 1460.62; found, m/z 1460.99. Anal. Calcd for C₇₂H₁₁₆O₁₄SSi₈: C, 59.13; H, 7.99; S, 2.19; Si, 15.36. Found: C, 59.05; H, 8.08; S, 2.14; Si, 15.29.

Entry	Solvent ^a	Catalyst ^b	Separated yield (%)			
			POSS-AN ₈	POSS-AN ₁₅	POSS-AN ₂₁	
1	THF	Et_3N	13.9			
2	THF	PPh₃	38.9			
3	THF	DABCO	41.4			
3	DMF	DABCO	20.6			
4	DMSO	DABCO	22.9			
5	DMF/THF	DABCO	44.3			
6	DMF/THF	DABCO	48.0	43.8	44.9	
7	DMSO/THF	DABCO ^c	56.2	54.1	55.3	
8	DMSO/THF	DABCO	61.2	58.4	59.1	
9	DMSO/THF	Et_3N	19.9			
10	DMSO/THF	PPh ₃	25.8			
^{<i>a</i>} The mix solvent is in volume ratio of 1:1. ^{<i>b</i>} The catalyst is 0.1 mol equivalent, temperature is						
80 °C, ^c temperature is 70 °C.						



Fig. S2 29 Si NMR of POSS-AN $_{21}$ in CDCl₃.







Fig. S6 TGA thermograms of POSS-AN₈, POSS-AN₁₅ and POSS-AN₂₁ recorded under nitrogen at a heating rate of 20 °C/min.



Fig. S7 DSC thermograms of POSS-AN₈, POSS-AN₁₅ and POSS-AN₂₁ recorded under nitrogen at a heating rate of 10 °C/min.



Fig. S8 Optimized molecular structures of POSS-AN $_8$, POSS-AN $_{15}$ and POSS-AN $_{21}$ calculated using the B3LYP/6-31G(d,p) basis set.

Upit	۲ (۸)	Surface area	Occupied volume
Onit	u (A)	(Ų)	(Å ³)
POSS-AN ₈	29.6	1210.6	1363.0
POSS-AN ₁₅	36.4	1321.1	1500.3
POSS-AN ₂₁	42.4	1421.6	1625.0

Table S2. The surface area and occupied volume of POSS-AN₈, POSS-AN₁₅ and POSS-AN₂₁ calculated using the B3LYP/6-31G(d,p) basis set.



Fig. S9 ¹H NMR of POSS-AN₈ in CDCl₃.



Fig. S10 ¹³C NMR of POSS-AN₈ in CDCl₃.



Fig. S11 $^{\rm 29}Si$ NMR of POSS-AN_8 in CDCl_3.



Fig. S12 FTIR of POSS-AN $_8$ in KBr.















Fig. S16 $^{\rm 29}Si$ NMR of POSS-AN $_{\rm 15}$ in CDCl_3.







Fig. S18 MALDI-TOF spectrum of POSS-AN₁₅.



Fig. S19 The curves of fluorescence intensity vs content of water measured of POSS-AN₂₁ at $386 \text{ nm} (\bullet)$ and 470 nm (•).



Fig. S20 (a) Fluorescence spectra of POSS-AN₈ in THF/H₂O. λ_{ex} = 318 nm, [C] = 10⁻⁴ M. (b) The curves of fluorescence intensity *vs* content of water measured of POSS-AN₈ at 386 nm (**■**) and 470 nm (**●**).



Fig. S21 (a) Fluorescence spectra of POSS-AN₁₅ in THF/H₂O. λ_{ex} = 318 nm, [C] = 10⁻⁴ M. (b) The curves of fluorescence intensity *vs* content of water measured of POSS-AN₁₅ at 386 nm (\blacksquare) and 470 nm (\bullet).



ig. S22 SEM images of solid samples prepared through air-drying the collected solution from column chromatography (hexane/dichloromethane): (a) POSS-AN₈, (b) POSS-AN₁₅ and (c) POSS-AN₂₁.



Fig. S23 SEM images of solid samples prepared from THF solution by freeze drying to move THF: (a) POSS-AN₈, (b) POSS-AN₁₅ and (c) POSS-AN₂₁.



g. S24 TEM images of solid samples prepared through air-drying the collected solution from column chromatography (hexane/dichloromethane): (a) POSS-AN₈, (b) POSS-AN₁₅ and (c) POSS-AN₂₁.



Fig. S25 X-ray diffraction patterns at the low angle region of POSS-AN₈, POSS-AN₁₅ and POSS-AN₂₁. All samples are prepared through air-drying the collected solution from column chromatography (hexane/dichloromethane).



Fig. S26 Illustration of self-assembly of TPE-modified POSS molecules in THF and THF/water.